International TOR Rectifier

REPETITIVE AVALANCHE AND dv/dt RATED HEXFET® TRANSISTOR

IRH7450 IRH8450

N CHANNEL
MEGA RAD HARD

500Volt, 0.45Ω , MEGA RAD HARD HEXFET

International Rectifier's RAD HARD technology HEXFETs demonstrate excellent threshold voltage stability and breakdown voltage stability at total radiaition doses as high as 1x106 Rads(Si). Under **identical** pre- and post-irradiation test conditions, International Rectifier's RAD HARD HEXFETs retain **identical** electrical specifications up to 1 x 105 Rads (Si) total dose. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1 x 1012 Rads (Si)/Sec, and return to normal operation within a few microseconds. Since the RAD HARD process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters. They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

Product Summary

Part Number	BVDSS	RDS(on)	lb
IRH7450	500V	0.45Ω	11A
IRH8450	500V	0.45Ω	11A

Features:

- Radiation Hardened up to 1 x 10⁶ Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed

Absolute Maximum Ratings ①

Pre-Irradiation

	Parameter	IRH7450, IRH8450	Units
ID @ VGS = 12V, TC = 25°C	Continuous Drain Current	11	
ID @ VGS = 12V, TC = 100°C	Continuous Drain Current	7.0	Α
I _{DM}	Pulsed Drain Current @	44	
P _D @ T _C = 25°C	Max. Power Dissipation	150	W
	Linear Derating Factor	1.2	W/°C
VGS	Gate-to-Source Voltage	±20	V
EAS	Single Pulse Avalanche Energy 3	500	mJ
IAR	Avalanche Current ②	11	Α
EAR	Repetitive Avalanche Energy@	15	mJ
dv/dt	Peak Diode Recovery dv/dt 4	3.5	V/ns
ТЈ	Operating Junction	-55 to 150	
TSTG	Storage Temperature Range		°C
	Lead Temperature	300 (0.063 in. (1.6mm) from case for 10s)	
	Weight	11.5 (typical)	g

Electrical Characteristics @ Tj = 25°C (Unless Otherwise Specified) ①

	Parameter	Min	Тур	Max	Units	Test Conditions		
BVDSS	Drain-to-Source Breakdown Voltage	500	_	_	V	VGS = 0V, ID = 1.0mA		
ΔBV _{DSS} /ΔT _J	Temperature Coefficient of Breakdown Voltage	_	0.6	-	V/°C	Reference to 25°C, I _D = 1.0mA		
RDS(on)	Static Drain-to-Source On-State	_	_	0.45	Ω	VGS = 12V, ID = 7.0A ⑤		
	Resistance	_	_	0.50		VGS = 12V, ID = 11A ⑤		
VGS(th)	Gate Threshold Voltage	2.0	_	4.0	V	$V_{DS} = V_{GS}$, $I_{D} = 1.0 \text{mA}$		
gfs	Forward Transconductance	4.0	_	_	S (℧)	VDS > 15V, IDS = 7A ⑤		
IDSS	Zero Gate Voltage Drain Current	_	_	50	μΑ	V _{DS} = 0.8 x Max Rating,V _{GS} =0V		
		_	—	250	μΛ	V _{DS} = 0.8 x Max Rating		
						VGS = 0V, TJ = 125°C		
IGSS	Gate-to-Source Leakage Forward	_	_	100	nA	VGS = 20V		
IGSS	Gate-to-Source Leakage Reverse	_	_	-100	IIA	V _{GS} = -20V		
Qg	Total Gate Charge	_	_	150		VGS =12V, ID =11A		
Qgs	Gate-to-Source Charge	_	—	30	nC	V _{DS} = Max Rating x 0.5		
Q _{gd}	Gate-to-Drain ('Miller') Charge	_	_	75				
td(on)	Turn-On Delay Time	_	_	45		V _{DD} = 250V, I _D = 11A,		
tr	Rise Time	_	_	190	ns	$R_G = 2.35\Omega$		
^t d(off)	Turn-Off Delay Time	_	_	190	115			
tf	Fall Time	_	_	130				
LD	Internal Drain Inductance	_	5.0	_	nH	Measured from drain lead, 6mm (0.25 in) bol showing the internal from package to center inductances.		
LS	Internal Source Inductance	_	13	_	-	of die. Measured from source lead, 6mm (0.25 in) from package to source bonding pad.		
Ciss	Input Capacitance	_	4000			VGS = 0V, VDS = 25V		
Coss	Output Capacitance	_	330	_	pF	f = 1.0MHz		
C _{rss}	Reverse Transfer Capacitance	_	52	_				

Source-Drain Diode Ratings and Characteristics 0

	Parameter	Min	Тур	Max	Units	Test Conditions	
Is	Continuous Source Current (Body Diode)	1-	-	11	Α	Modified MOSFET symbol	
ISM	Pulse Source Current (Body Diode) ②		_	44		showing the integral reverse p-n junction rectifier.	
VSD	Diode Forward Voltage		-	1.6	V	Tj = 25°C, IS = 11A, VGS = 0V ⑤	
t _{rr}	Reverse Recovery Time		_	1100	ns	Tj = 25°C, Iϝ = 11A, di/dt ≤ 100A/μs	
QRR	Reverse Recovery Charge	—	—	16	μС	V _{DD} ≤ 50V ⑤	
ton	Forward Turn-On Time Intrinsic turn-o	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by Lg + Lp.					

Thermal Resistance

	Parameter	Min	Тур	Max	Units	Test Conditions
RthJC	Junction-to-Case	_	_	0.83		
RthJA	Junction-to-Ambient	_	_	30	°C/W	
RthCS	Case-to-Sink	_	0.12	_		Typical socket mount

Radiation Performance of Rad Hard HEXFETs

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier comprises three radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019 condition A. International Rectifier has imposed a standard gate condition of 12 volts per note 6 and a $V_{\rm DS}$ bias condition equal to 80% of the device rated voltage per note 7. Pre- and post- irradiation limits of the devices irradiated to 1 x 10 $^{\rm 5}$ Rads (Si) are identical and are presented in Table 1, column 1, IRH7450. Post-irradiation limits of the devices irradiated to 1 x 10 $^{\rm 6}$ Rads (Si) are presented in Table

1, column 2, IRH8450. The values in Table 1 will be met for either of the two low dose rate test circuits that are used. Both pre- and post-irradiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison.

High dose rate testing may be done on a special request basis using a dose rate up to 1 x 10¹² Rads (Si)/ Sec (See Table 2).

International Rectifier radiation hardened HEXFETs have been characterized in heavy ion Single Event Effects (SEE) environments. Single Event Effects characterization is shown in Table 3.

Table 1. Low Dose Rate 6 © IRH7450 IRH8450

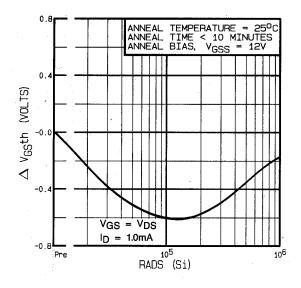
Table 1: Low Dose Nate & &		11(117-100		111110-100			
	Parameter	100K F	100K Rads (Si)		1000K Rads (Si)		Test Conditions ®
		Min	Max	Min	Max		
BV _{DSS}	Drain-to-Source Breakdown Voltage	500	_	500	_	٧	$V_{GS} = 0V, I_{D} = 1.0mA$
V _{GS(th)}	Gate Threshold Voltage	2.0	4.0	1.25	4.5		$V_{GS} = V_{DS}$, $I_D = 1.0 \text{mA}$
IGSS	Gate-to-Source Leakage Forward		100	_	100	nA	V _{GS} = 20V
IGSS	Gate-to-Source Leakage Reverse	_	-100	_	-100		V _{GS} = -20 V
IDSS	Zero Gate Voltage Drain Current	_	50	_	100	μA	V _{DS} =0.8 x Max Rating, V _{GS} =0V
R _{DS(on)1}	Static Drain-to-Source ⑤	_	0.45	_	0.6	Ω	Vgs = 12V, I _D = 7.0A
	On-State Resistance One						
V_{SD}	Diode Forward Voltage ⑤	_	1.6	_	1.6	V	$T_C = 25^{\circ}C$, $I_S = 11A$, $V_{GS} = 0V$

Table 2. High Dose Rate ®

		10 ¹¹ Rads (Si)/sec 10 ¹² Rads (Si)/sec							
	Parameter	Min	Тур	Max	Min	Тур	Max	Units	Test Conditions
VDSS	Drain-to-Source Voltage	_	_	400	_	_	400	V	Applied drain-to-source voltage during
									gamma-dot
IPP		_	8	_	_	8	_	Α	Peak radiation induced photo-current
di/dt		_	_	15	_	_	3	A/µsec	Rate of rise of photo-current
L ₁		27	_	_	133	_	_	μH	Circuit inductance required to limit di/dt

Table 3. Single Event Effects

lon	LET (Si)	Fluence	Range	V _{DS} Bias	V _{GS} Bias
	(MeV/mg/cm²)	(ions/cm²)	(µm)	(V)	(V)
Cu	28	3x 10 ⁵	~43	275	-5



VGS = 12V
ID = 7.0A

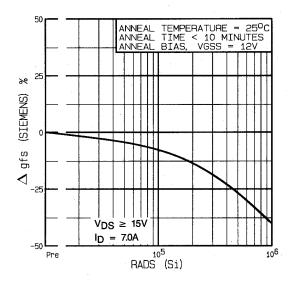
VGS = 12V
ID = 7.0A

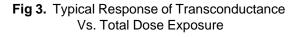
ANNEAL TEMPERATURE = 25°C
ANNEAL TIME < 10 MINUTES
ANNEAL TIME < 10 MINUTES
ANNEAL BIAS, VGSS = 12V

105
RADS (Si)

Fig 1. Typical Response of Gate Threshhold Voltage Vs. Total Dose Exposure

Fig 2. Typical Response of On-State Resistance Vs. Total Dose Exposure





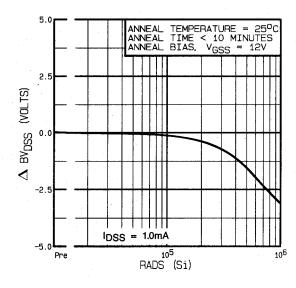


Fig 4. Typical Response of Drain to Source Breakdown Vs. Total Dose Exposure

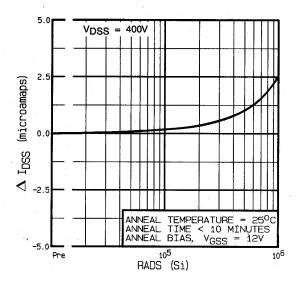


Fig 5. Typical Zero Gate Voltage Drain Current Vs. Total Dose Exposure

Fig 6. Typical On-State Resistance Vs. Neutron Fluence Level

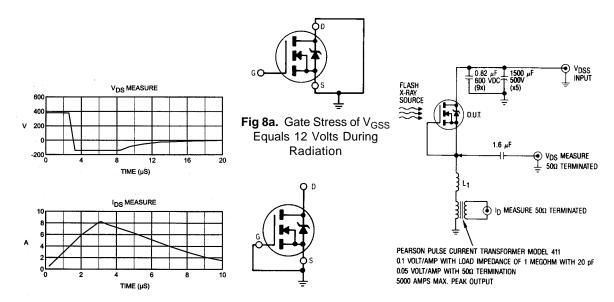


Fig 7. Typical Transient Response of Rad Hard HEXFET During 1x10¹² Rad (Si)/Sec Exposure

Fig 8b. V_{DSS} Stress Equals 80% of B_{VDSS} During Radiation

Fig 9. High Dose Rate (Gamma Dot) Test Circuit

Note: Bias Conditions during radiation: Vgs = 12 Vdc, Vps = 0 Vdc

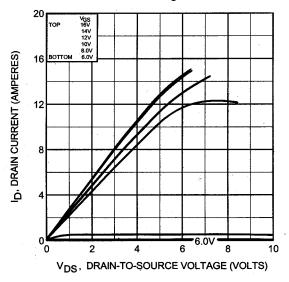


Fig 10. Typical Output Characteristics Pre-Irradiation

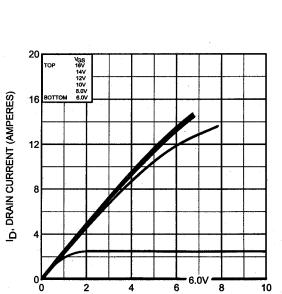


Fig 12. Typical Output Characteristics Post-Irradiation 300K Rads (Si)

V_{DS}, DRAIN-TO-SOURCE VOLTAGE (VOLTS)

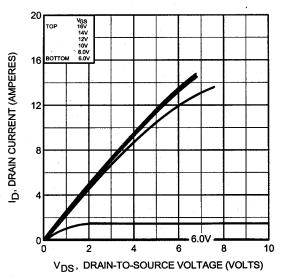


Fig 11. Typical Output Characteristics Post-Irradiation 100K Rads (Si)

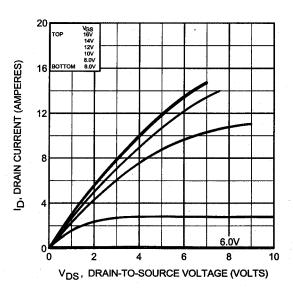


Fig 13. Typical Output Characteristics Post-Irradiation 1 Mega Rads(Si)

Radiation Characterstics

IRH7450, IRH8450 Devices

Note: Bias Conditions during radiation: Vgs = 0 Vdc, Vps = 400 Vdc

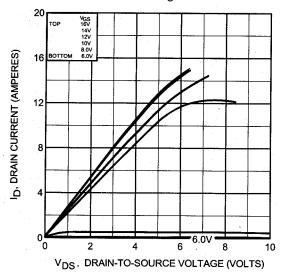


Fig 14. Typical Output Characteristics Pre-Irradiation

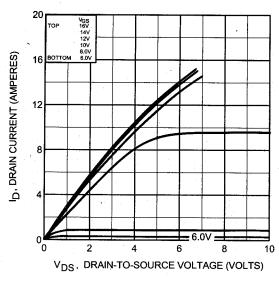


Fig 15. Typical Output Characteristics Post-Irradiation 100K Rads (Si)

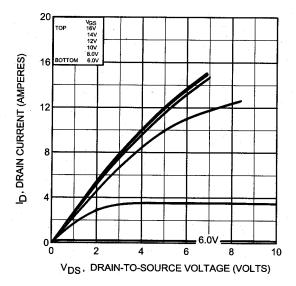


Fig 16. Typical Output Characteristics Post-Irradiation 300K Rads (Si)

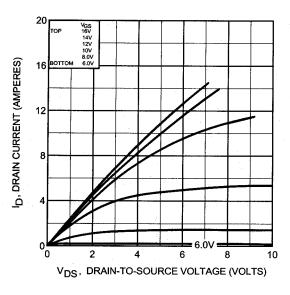


Fig 17. Typical Output Characteristics Post-Irradiation 1 Mega Rads(Si)

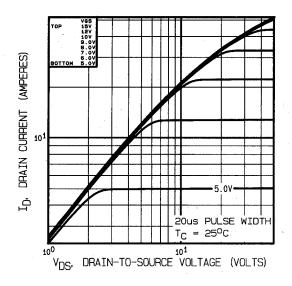


Fig 18. Typical Output Characteristics

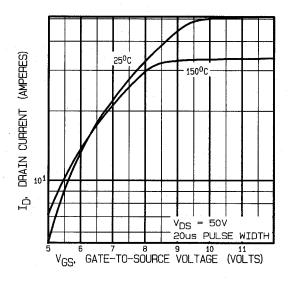


Fig 20. Typical Transfer Characteristics

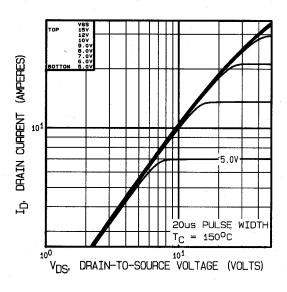


Fig 19. Typical Output Characteristics

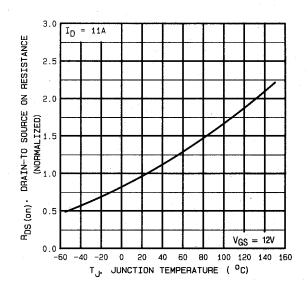


Fig 21. Normalized On-Resistance Vs. Temperature

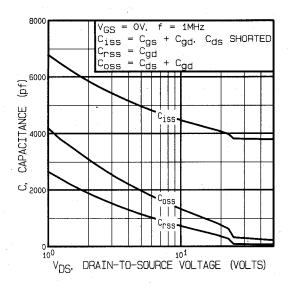


Fig 22. Typical Capacitance Vs. Drain-to-Source Voltage

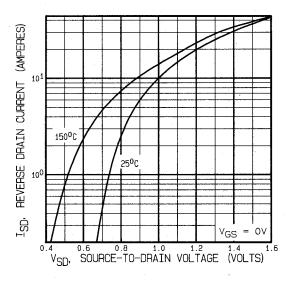


Fig 24. Typical Source-Drain Diode Forward Voltage

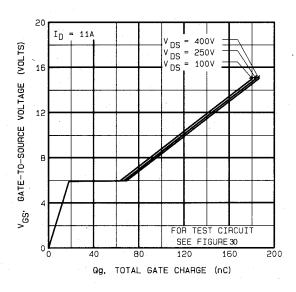


Fig 23. Typical Gate Charge Vs. Gate-to-Source Voltage

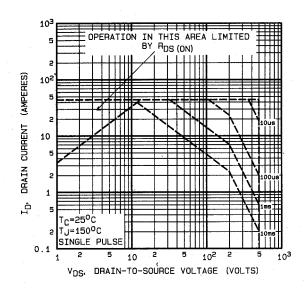


Fig 25. Maximum Safe Operating Area

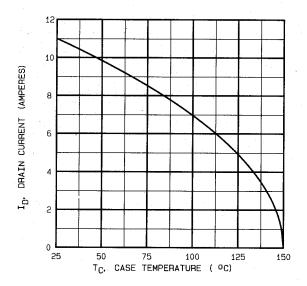


Fig 26. Maximum Drain Current Vs. Case Temperature

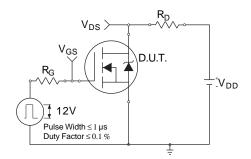


Fig 27a. Switching Time Test Circuit

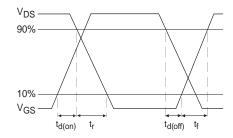


Fig 27b. Switching Time Waveforms

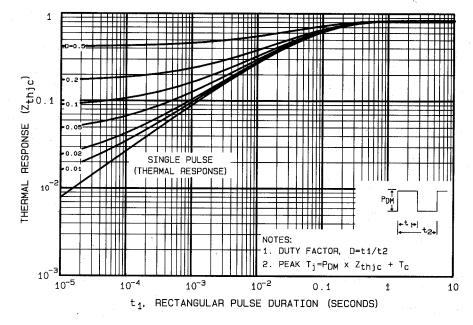


Fig 28. Maximum Effective Transient Thermal Impedance, Junction-to-Case

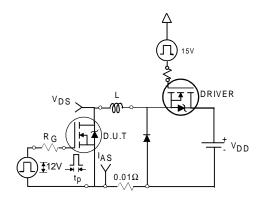


Fig 29a. Unclamped Inductive Test Circuit

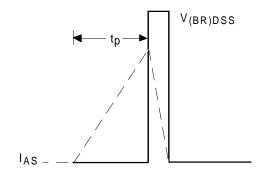


Fig 29b. Unclamped Inductive Waveforms

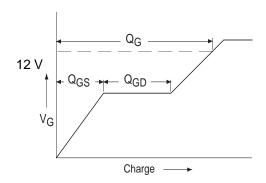


Fig30a. Basic Gate Charge Waveform

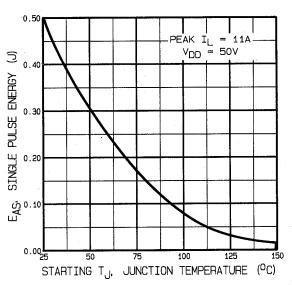


Fig 29c. Maximum Avalanche Energy Vs. Drain Current

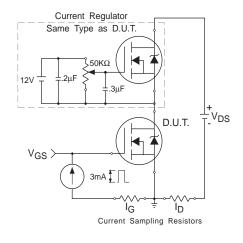


Fig 30b. Gate Charge Test Circuit

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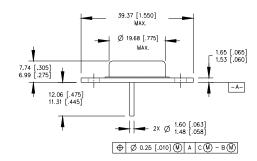
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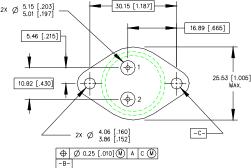
Pre-Irradiation

- See Figures 18 through 30 for pre-irradiation curves
- ② Repetitive Rating; Pulse width limited by maximum junction temperature. Refer to current HEXFET reliability report.
- ③ $V_{DD} = 25V$, Starting $T_J = 25$ °C, Peak $I_L = 11A$, L>7.4mH $R_G=25\Omega$
- ⊕ I_{SD} ≤ 11A, di/dt ≤ 120A/µs, V_{DD} ≤ BV_{DSS}, T_J ≤ 150°C Suggested RG =2.35Ω
- ⑤ Pulse width \leq 300 μ s; Duty Cycle \leq 2%

- ® Total Dose Irradiation with V_G\$ Bias.
 12 volt V_G\$ applied and V_D\$ = 0 during irradiation per MIL-STD-750, method 1019, codition A.
- Total Dose Irradiation with Vps Bias.
 Vps = 0.8 rated BVpss (pre-radiation)
 applied and Vgs = 0 during irradiation per
 MIL-STD-750, method 1019, condition A.
- ® This test is performed using a flash x-ray source operated in the e-beam mode (energy ~2.5 MeV), 30 nsec pulse.
- All Pre-Irradiation and Post-Irradiation test conditions are identical to facilitate direct comparison for circuit applications.

Case Outline and Dimensions — TO-204AE





Conforms to JEDEC Outline TO-204AE Dimensions in Millimeters and (Inches)

PIN ASSIGNMENTS

- 1 SOURCE
- 2 GATE
- 3 DRAIN (CASE)

NOTES:

- 1. DIMENSIONING & TOLERANCING PER ANSI Y14.5M-1982.
- 2. CONTROLLING DIMENSION: INCH.
- DIMENSIONS ARE SHOWN IN MILLIMETERS [INCHES].
- 4. OUTLINE CONFORMS TO JEDEC OUTLINE TO-204AE.

International

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